

Inscription(s)

Type IIa

ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

LABORATORY GROWN DIAMOND REPORT

LG628472172 Report verification at igi.org

58%

Pointed

34.1°

40.8°

60%

LABORATORY GROWN DIAMOND REPORT

GRADING SCALES

CLARITY

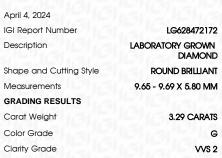
IF	VVS ¹⁻²	VS ¹⁻²	SI ¹⁻²	l ¹⁻³
Internally	Very Very	Very	Slightly	Included
Flawless	Slightly Included	Slightly Included	Included	

COLOR

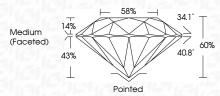
D	Е	F	G	Н	L	J	Faint	Very Light	Light
								, .	-

(15) LG628472172

Sample Image Used



LABORATORY GROWN DIAMOND REPORT



Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	NONE
Inscription(s)	低到 LG628472172
Comments: This Laboratory created by Chemical Vapo process and may include p	or Deposition (CVD) growth



Type IIa

Cut Grade IDEAL



Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	NONE
inscription(s)	(G) LG628472172
Comments: This Laboratory created by Chemical Vapo process and may include a	or Deposition (CVD) growth



Comments: The Laboratory Grown Diamond was taboratory Grown Diamond was CADD growth processe and may include post-growth treatment. (type lid	Comments: This Loordony Grown created by Chemical (CVD) growth process post-growth theritment. Type IIa
(g) LG628472172	Inscription(s)
NONE	Fluorescence
EXCELLENT	Symmetry
EXCELLENT	Polish
Pointed	Culet
Medium (Faceted)	Girdle
26%	Table
\$09	Depth
IDEAL	Out Grade
WS2	Clarity Grade
Ø	Color Grade

PROPORTIONS

Medium

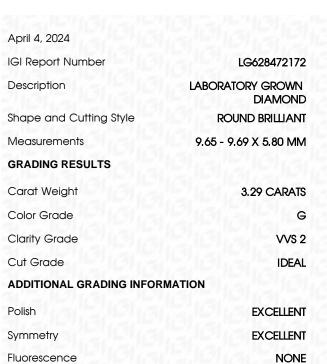
(Faceted)

14%

43%

CLARITY CHARACTERISTICS

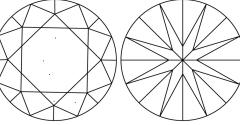
 \checkmark



Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth

process and may include post-growth treatment.

1/31 LG628472172



KEY TO SYMBOLS

Red symbols indicate internal characteristics. Green symbols indicate external characteristics.

www.igi.org

© IGI 2020, International Gemological Institute

THIS DOCUMENT WAS PRODUCED WITH THE FOLLOWING SECURITY MEASURES: SPECIAL DOCUMENT PAPER, INK SCREENS, WATERMARK BACKGROUND DESIGNS, HOLOGRAM AND OTHER SECURITY FEATURES NOT LISTED AND DO EXCEED DOCUMENT SECURITY INDUSTRY GUIDELINES.